

EAST Search History

| Ref # | Hits | Search Query | DBs | Default Operator | Plurals | Time Stamp |
|-------|------|---|----------------------------|------------------|---------|------------------|
| L2 | 518 | 438/753.ccls. | US-PGPUB; USPAT | OR | OFF | 2006/09/21 13:37 |
| L3 | 23 | ("2902419" "3434896" "3480474" "3505132" "3506509" "3846198" "3909325" "4061783" "4061784" "4137123" "4490181" "4579591").PN. OR ("4859280").URPN. | US-PGPUB; USPAT; USOCR | OR | OFF | 2006/09/21 13:44 |
| L4 | 7 | ("3434896").URPN. | USPAT | OR | OFF | 2006/09/21 13:46 |
| L5 | 5110 | 438/424.ccls. 438/478.ccls. 438/479.ccls. 438/482.ccls. 438/488.ccls. 438/753.ccls. 216/99.ccls. | US-PGPUB; USPAT | OR | OFF | 2006/09/21 13:47 |
| L6 | 59 | L5 and ((silicon si polysilicon poly) same (fluorine fluoride hf hydrofluoric "nh.sub.4f" "nh.sub.4f" hydroxide ammonium tmah "nh.sub.4oh" "nh.sub.4 oh") same ph) | US-PGPUB; USPAT | OR | ON | 2006/09/21 13:47 |
| L7 | 54 | (silicon si polysilicon poly) and ((etch\$6 dissolv\$6 remov\$6) near4 (liquid base acid basic acidic wet)) and (fluorine fluoride hf hydrofluoric "nh.sub.4f" "nh.sub.4f") and (hydroxide ammonium tmah "nh.sub.4oh" "nh.sub.4 oh") and ph | EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2006/09/21 13:50 |
| L8 | 2 | 5 and ((silicon si polysilicon poly) same (((etch\$6 dissolv\$6 remov\$6) near4 (liquid base acid basic acidic wet)) with (fluorine fluoride hf hydrofluoric "nh.sub.4f" "nh.sub.4f") with (hydroxide ammonium tmah "nh.sub.4oh" "nh.sub.4 oh")) same ph) | US-PGPUB; USPAT | OR | ON | 2006/09/21 13:55 |
| L9 | 77 | (silicon si polysilicon poly) same ((etch\$6 dissolv\$6 remov\$6) near4 (liquid base acid basic acidic wet)) same (fluorine fluoride hf hydrofluoric "nh.sub.4f" "nh.sub.4f") same (hydroxide ammonium tmah "nh.sub.4oh" "nh.sub.4 oh") same ph | US-PGPUB; USPAT | OR | ON | 2006/09/21 14:03 |
| L10 | 3 | "3434896".pn. "5099304".pn. "6955972".pn. | US-PGPUB; USPAT | OR | OFF | 2006/09/21 14:04 |

EAST Search History

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| L11 | 35 | ((silicon si polysilicon poly) and ((etch\$6 dissolv\$6 remov\$6) near4 (liquid base acid basic acidic wet)) and (fluorine fluoride hf hydrofluoric "nh.sub.4f" "nh.sub.4 f") and (hydroxide ammonium tmah "nh.sub.4oh" "nh.sub.4 oh") and ph).clm. | US-PGPUB | OR | ON | 2006/09/21 14:28 |
|-----|----|---|----------|----|----|------------------|